IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants:

HAGIWARA, et al.

Application No.:

TBD

Filed:

November 17, 2003

For:

PHOTOSENSITIVE RESIN COMPOSITION

Expected

Group:

1752

Expected

Examiner:

J. Chu

PRELIMINARY AMENDMENT

Mail Stop Patent Application Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 November 17, 2003

Sir:

Please amend the above-identified application, prior to examination thereof, as listed in the following, and as set forth on the following pages:

Amendments to the Specification; and

Remarks are included following the amendments.